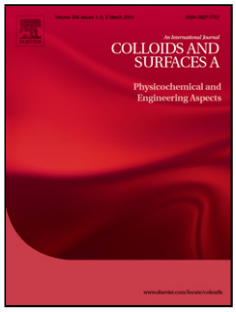

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Investigations on Bubble Growth Mechanism during Photoelectrochemical and Electrochemical Conversions

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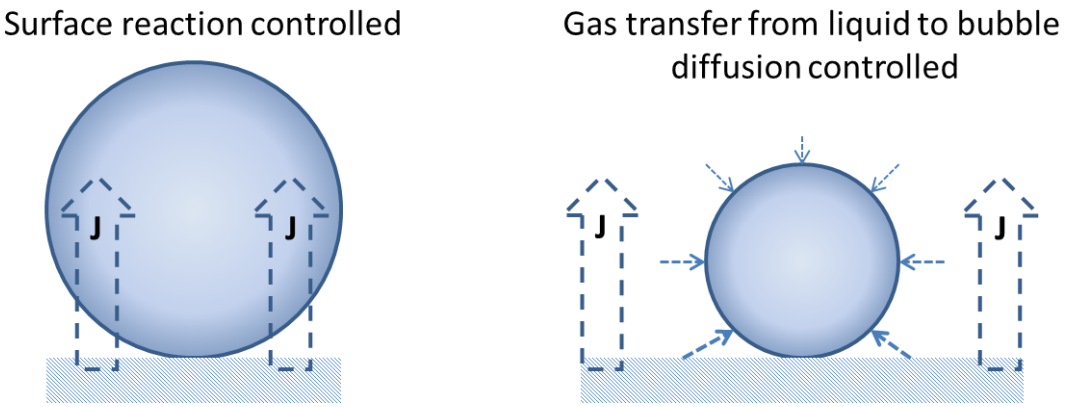
Graphical abstract



Highlights

- ✧ A reaction cell meeting the requirements of photoelectrochemical and electrochemical conversions were set up for gas-evolving investigation.
- ✧ Bubble grows as $R \sim t^{0.3}$ in photoelectrochemical conversion due to the small effective solid surface engaged; while bubble grows as $R \sim t^{0.5}$ in the electrochemical conversion due to the big